

Loft

INFORMATION DISCLOSURE CITATION
IN AN APPLICATION

SEP 2 (If you don't know, show it if necessary)

Dashes (Horizontal) (Options)

TSMC-00-776 B

Hydrogen Peroxide

10/613,694

Agenda

Applicant Yang-Tung Fan et al.

Filing Date

07/03/03

Group Art Unit

U. S. PATENT DOCUMENTS

[illegible]

FOREIGN PATENT DOCUMENTS

[illegible]

OTHER DOCUMENTS (Including Author, Title, Date, Portion or Pages, Etc.)

[illegible]

EXAMINER

Michael Trinh

DATE CONSIDERED

6/7104

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.